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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **HAEMATSU, Hitoshi**

Group Art Unit: **2822**

Serial No.: **10/659,337**

Examiner: **Pamela E. PERKINS**

Filed: **September 11, 2003**

**P.T.O. Confirmation No.: 7094**

For: **SEMICONDUCTOR DEVICE AND MANUFACTURING METHOD THEREOF**

**AMENDMENT UNDER 37 CFR §1.111**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

August 23, 2004

Sir:

In response to the Office Action dated **May 21, 2004**, please amend the above-identified application as follows:

**Amendments to the Drawings** begin on page 2 of this paper and include an attached replacement sheet and an annotated sheet showing changes.

**Amendments to the Specification** begin on page 3 of this paper.

**Remarks/Arguments** begin on page 16 of this paper.

U.S. Patent Application Serial No. 10/659,337  
Reply to Office Action dated May 21, 2004

**AMENDMENT TO THE DRAWINGS:**

The attached sheet of drawings includes changes to Fig. 8A-8E.